

O I P E  
DEC 08 2003

1/4

FIG. 1

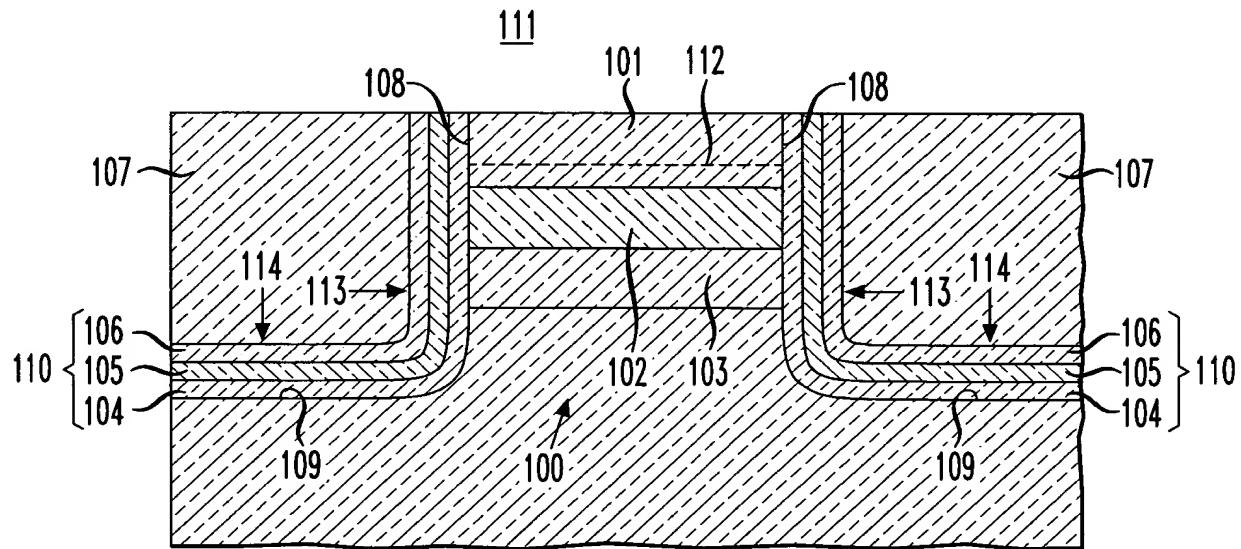
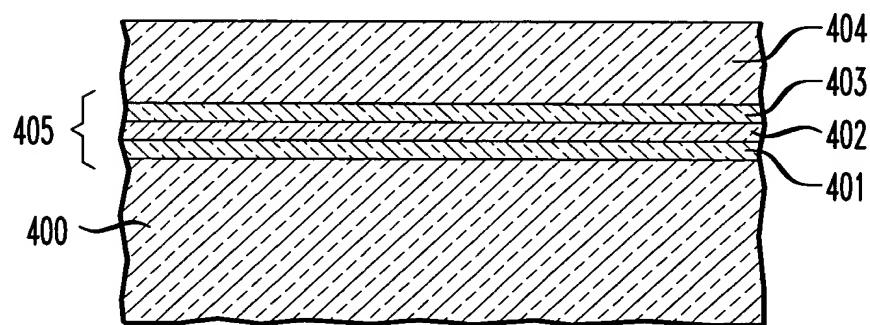


FIG. 4



AKULOV 3-12-10 SERIAL NO. 09/645,913

APPLICATION OF InAlAs DOUBLE-LAYER TO BLOCK DOPANT OUT-DIFFUSION IN III-V DEVICE FABRICATION

LESTER H. BIRNBAUM (610) 530-9166

2/4

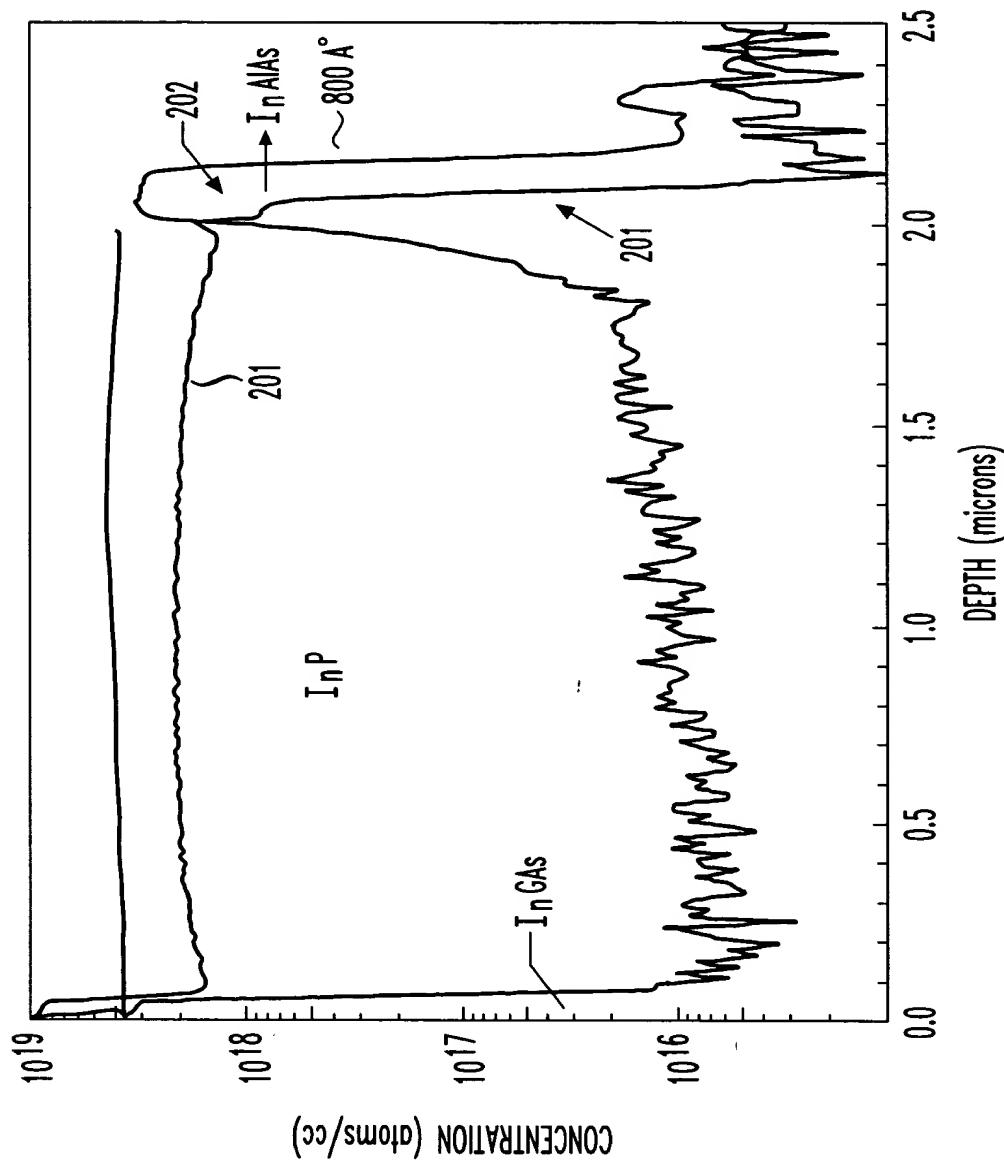


FIG. 2



AKULOV 3-12-10 SERIAL NO. 09/645,913

APPLICATION OF InAlAs DOUBLE-LAYER TO BLOCK DOPANT OUT-DIFFUSION IN III-V DEVICE FABRICATION

LESTER H. BIRNBAUM (610) 530-9166

3/4

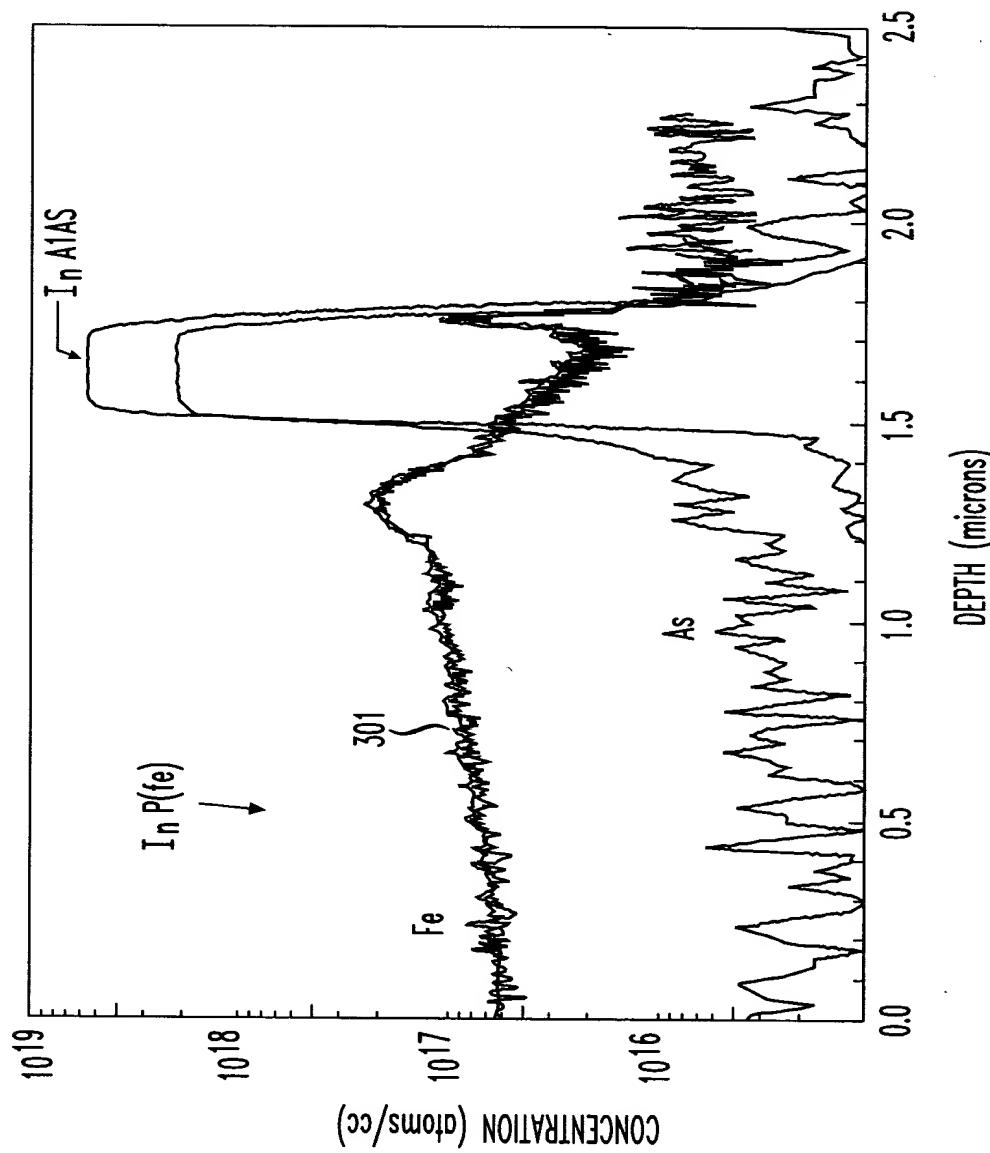


FIG. 3



AKULOV 3-12-10 SERIAL NO. 09/645,913

APPLICATION OF InAlAs DOUBLE-LAYER TO BLOCK DOPANT OUT-DIFFUSION IN III-V DEVICE FABRICATION

LESTER H. BIRNBAUM (610) 530-9166



4/4

*FIG. 5*

